

10/589830
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Amendment (Under Article 11 of the Law)

Date: January 17, 2006

To: Examiner,

1. International application number: PCT/JP2005/002211

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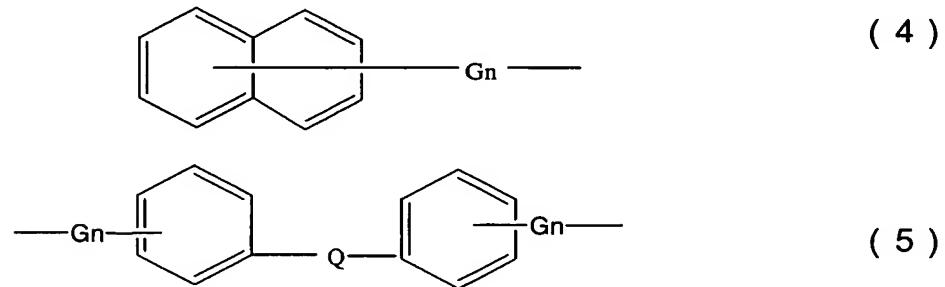
4. Item to be Amended: Claims

5. Contents of amendment As shown in another paper

(1) The seventh and subsequent rows of claim 1 are amended as shown below.

"where m represents an integer of 2 to 4, R's each represent an alkyl group having 1 to 6 carbon atoms, A represents a divalent to tetravalent aromatic residue represented by any one of the following general formulae (4) and (5), and Z represents an alicyclic residue produced by hydrogenation of the aromatic residue represented by A:

[Chem 2]



where G represents single bond, methylene group, ethylene group, or ethylidene group, Q represents single bond, oxygen atom, methylene group, ethylene group, ethylidene group, or isopropylidene group, n represents a number of G by which an aromatic ring is substituted and represents an integer of 2 to 4 in the general formula (4), and a total of n's in the general formula (5) represents an integer of 2 to 4."

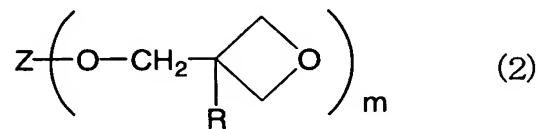
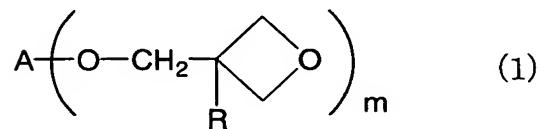
6. Catalogue of attached document

(1) Claims p. 13 and p. 13/1

CLAIMS

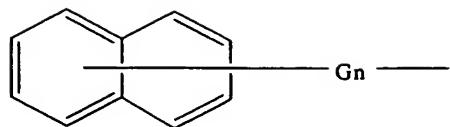
1. (After amendment) A process for producing an alicyclic oxetane compound represented by the following general formula (2), which comprising subjecting an aromatic ring of an aromatic oxetane compound having at least two oxetane rings and represented by the following general formula (1) to nuclear hydrogenation:

[Chem 1]

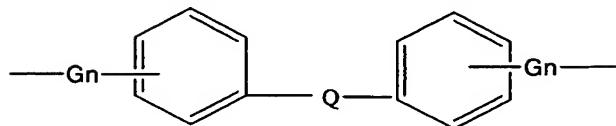


in the general formulae (1) and (2), m represents an integer of 2 to 4, R represents an alkyl group having 1 to 6 carbon atoms, A represents a divalent to tetravalent aromatic residue represented by any one of the following general formulae (4) to (5), and Z represents an alicyclic residue produced by hydrogenation of the aromatic residue represented by A:

[Chem 2]



(4)



(5)

in the general formulae (4), and (5), G represents single bond, methylene group, ethylene group, or ethylidene group, Q represents single bond, oxygen atom, methylene group, ethylene group, ethylidene group, or isopropylidene group, n represents a number of G by which an aromatic ring is substituted and represents an integer of 2 to 4 in each of the general formulae (4), and a total of n in the general formula (5) represents an integer of 2 to 4.